Investigation on Lanthanum Fluoride as a Novel Cathode Buffer Material Layer for the Enhancement of Stability and Performance of Organic Solar Cell

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Abstract

This article presents the investigation on very thin Lanthanum Fluoride (LaF₃) layer as a new cathode buffer layer (CBL) for organic solar cell (OSC). OSCs were fabricated with poly(3-hexylthiophene) (P3HT) and phenyl-C₆₁-butyric acid methyl ester (PCBM) polymer blend at 1:1 ratio. Electron-beam evaporation at room temperature was used to deposit 3 and 5 nm thick LaF₃ layer. A very smooth surface of LaF₃ with an average roughness of 0.2 nm has been observed by the Atomic Force Microscope (AFM) that is expected to prevent diffusion of cathode metal ion through it and thereby enhance the lifetime and stability of OSC. Huge enhancement of $J_{SC}$ and $V_{OC}$ was also observed for 3 nm-thick LaF₃ CBL. Several excellent features of the LaF₃ layer such as, transporting electron through tunneling, blocking of holes to the cathode, minimizing recombination, protecting the photoactive polymer from ambient oxygen, and reducing degradation/oxidation of any low work function layer at the cathode interface, might have contributed to the performance enhancement of OSC. The experimental findings indicate the promise of LaF₃ to be an excellent CBL material for OSC.

Keywords

Organic Semiconductor, Photoactive Polymer, Organic Solar Cell, Bulk Heterojunction Solar Cells, Cathode Buffer Layer, Lanthanum Fluoride, Spin Coating, E-Beam Evaporation

1. Introduction

Solar cells utilizing organic materials have recently become of great interest due to their potential to utilize high throughput and low-cost solution phase processing [1]-[6]. But, before OSCs can be commercialized practical limitations of OSCs such as low power conversion efficiency (PCE) that results from the low open-circuit voltage (V_{OC}), short-circuit current (J_{SC}) and fill factor (FF) and limited operational lifetime must be overcome. The overall performance of OSCs can be increased by various ways such as controlling the architecture, morphology, processing, and the fundamental electronic processes photoactive layers. Most research has focused on the photoactive layer and control of their morphology to achieve high efficiency of OSCs [7]-[9]. Whereas, performances of OSCs, such as the electron extraction and V_{OC}, are also found to depend largely on the interfacial layers between a photoactive layer and electrodes [10]-[12], and why it is necessary to develop interfacial layers to further improve the efficiency.

Use of appropriate electrodes materials or introducing charge extraction layers can be used to improve V_{OC} and charge extraction of both the electrodes. When a buffer layer is used at the electrodes it produces a non-ohmic contact and the V_{OC} is determined by the difference in work-function between the two electrodes instead of the difference in (HOMO) level of the donor (PCBM) and the lowest unoccupied molecular orbital (LUMO) level of the acceptor (P3HT) for ohmic contact [13]. The stability of the organic solar cell is also a big concern as the cathode-material ion diffuses through the active layer which can react with the polymer and alter its semi-conducting properties [14]. Another degradation phenomenon is the formation of insulating metal-oxide layer at the cathode interface [15]. Therefore, stability can be improved by using efficient diffusion barrier material having less air sensitivity. Improvement of V_{OC} and charge extraction has been done by modifying electrodes or introducing charge extraction layers. Various metal fluorides, TiO_{x}, and low work function cathodes have been reported to improve the electron injection/extraction contact [16]-[21].

In a quest of finding a new cathode buffer layer (CBL) that will protect the organic layer from the direct deposition of hot Al vapor and prevent damages, act as a diffusion barrier for both Al, exciton and hole and form oriented dipoles at the interface of the organic layer that improves the electron extraction, in this report LaF_{3} has been investigated as a new CBL between the polymer bulk-heterojunction and Al-cathode. LaF_{3} has been considered because it posses the mentioned features [22] [23]. The main objective of this study is to investigate the effect of incorporation of very thin LaF_{3} layer between the photoactive polymer and Al-cathode on short-circuit current density (J_{SC}) and open circuit voltage (V_{OC}) of OSC. The effect of annealing on the performance of the OSC has been also investigated. The extremely smooth surface morphology of the e-beam evaporated amorphous LaF_{3} layer favours its diffusion barrier characteristics for ambient oxygen and Al ions. Very large ionization potential of LaF_{3} favours the blocking characteristics of photogenerated holes. Above all, huge improvement in the J_{SC} and V_{OC} has been observed for a 3 nm thick LaF_{3} layer. Experimental results suggest that the possibility of using a thin LaF_{3} buffer layer at the Al-cathode could enhance the performance and stability of OSC.

2. Experimental

Readymade blend of P3HT and PCBM at 1:1 ratio and PDOT were bought from Sigma-Aldrich Chemie GmbH Steinheim, Germany. The OSC fabrication began with the deposition of ITO on a properly cleaned glass substrate. Commercially available ITO powder (99.99% pure) was obtained from Inframat Advanced Materials, USA, and was used as the evaporation source material. Electron beam evaporation technique was used to deposit ITO thin films on glass substrate at room temperature using an Edwards E-306, vacuum coating unit. Glass substrates with 140 nm thick ITO film were annealed at 600°C for 10 min to obtain an optical transparency of >90% and electrical resistivity of 1.25 × 10^{-5} Ω·m. Hole transport layer (PDOT) was deposited on ITO film by spin coating. On PDOT layer P3HT:PCBM blend was spin coated to obtain a 90 nm thick layer. The device thus formed was annealed in a temperature-controlled furnace in air at 130°C for 2 min. The resulting structure of the OSC is schematically shown in Figure 1(b).

3. Results & Discussion

The roughness of the cathode buffer layer (CBL) is very important for the performance of the OSC. The light transmission through the layer is decreased and the efficiency of the OSC decreases with the increase in roughness [24] [25]. The roughness of the LaF_{3} layer was studied with AFM. Figure 2 shows the amplitude image of
Figure 1. Structure of proposed organic solar cell (a) conventional and (b) proposed.

- **Figure 2.** Surface morphology of LaF$_3$ layer (a) 3D topography and (b) image from error signal showing the thickness measurement and (c) roughness calculation.

The LaF$_3$ layer was selectively deposited on the P3HT:PCBM layer. Then AFM tip was scanned 30 × 30 nm scale at the interface between LaF$_3$ and P3HT:PCBM layer. As shown in Figure 2(b) the peak in the error signal indicated the thickness of the LaF$_3$ layer. The average roughness was found to be ~0.02 nm. Therefore very smooth surface was obtained by e-beam evaporation.
To act as a diffusion barrier layer that prevents diffusion of metal ion, in this case of LaF$_3$ layer to be the barrier of Al, amorphous films are desired, since grain boundaries between individual crystals would provide a leakage path for the diffusion of ions and lead to device failure [26]. The as deposited LaF$_3$ films were found to be amorphous and why it is expected that it will prevent Al ion to diffuse into the polymer photoactive layer [26].

The J-V characteristics of the fabricated OSCs (with and without LaF$_3$ CBL) were studied under forward and reverse bias condition in dark and under 1.5 AM simulated sunlight illumination. The comparison of J-V responses of the two types of OSCs is shown in Figure 3. It can be noticed from Figure 3 that the $J_{SC}$ was small for both the cases. Accordingly, the conversion efficiency, fill-factor of the solar cells was small. This was due to fabrication process used to fabricate the OSC, processing environment, quality of the polymer blend etc. As the mentioned factors were common during the fabrication of the two types of OSCs (with and without LaF$_3$ layer) the enhancement in performance can be attributed to the incorporation of LaF$_3$ interlayer. As shown in Figure 3 huge enhancement in short-circuit current density was observed. The comparative J-V response of the OSCs for three different thicknesses of LaF$_3$ layer is shown in Figure 4. The $J_{SC}$ was proportional to the thickness of the buffer layer. Electron tunneling is impossible with a LaF$_3$ layer as thick as 5 nm. The reduced $J_{SC}$ can be attributed to the increase in cell resistances induced by too thick layer. Thicker CBL produced no improvement as was reported for other interlayer [27]-[31] for organic light-emitting diodes. For this study it was found that the 3 nm of interlayer LaF$_3$ thickness showed the performance enhancement of the OSC. Further enhancement in short-circuit current density was observed when the whole device was annealed at a temperature of 150°C for 10 minute. Figure 4 shows the J-V characteristics with and without heat treatment. Similar improvement after annealing at 150°C for 30 min was observed for PCPDTBT-based solar cell with CdSe-QDs as the Al-cathode buffer layer [32]. It may be due to the improvement of contact between the photoactive material and electrode that arose from the decrease in the concentration of traps at interfaces and smoothing of the film surface. The experimentally obtained open-circuit voltage and short-circuit current density values for various thickness of the LaF$_3$ layers for the as deposited and after heat treatment are summarized in Table 1.

The improvement of VOC can be attributed to the increase of the built-in-potential of the devices with a LaF$_3$ layer resulting from the upward shift of the vacuum level at the cathode and the enhancement in $J_{SC}$ can be attributed to the efficient electron collection, which can be explained by a tunneling model [33]. Figure 5 displays the schematic energy-level diagram for conventional OSC and OSC cell with 3 nm LaF$_3$ CBL. The energy level value has been taken from [34]. The bending of conduction and valence bands becomes much steeper for the OSC with LaF$_3$ buffer layer than that without LaF$_3$ layer. Larger built-in-voltage can be expected if the difference in the effective work function between two electrodes is larger. Due to the increased band bending in PCBM excitons generated in the PCBM layer could diffuse to the interface of PCBM/LaF$_3$ and readily dissociate at the interface under the strong built-in electric field formed from the orbital bending near the junction.
Figure 4. J-V response of the fabricated OSC with LaF₃ buffer layer with and without heat treatment.

Figure 5. The vacuum level shift and energy levels in OSCs (a) without and (b) with LaF₃ CBL.

Due to increased electrical field the electrons can tunnel through 3 nm LaF₃ layer efficiently [35] [36]. Again, LaF₃ film is an electrical insulator and due to its exceptionally large surface polarization [37] [38] thin LaF₃ layer is expected to decrease the surface potential of the Al cathode and thus the effective work function, resulting in favorable electron extraction. These are all in good consistence with the obtained enhancement in J_{SC} and V_{OC}.

As shown in Figure 5(b) the LaF₃ layer can act as hole-blocking layer as the ionization potential of LaF₃ (12.4 eV) is much larger than that of PCBM (6.3 eV). LaF₃ also has a high electron affinity that enhances electron extraction from PCBM and blocks holes as a result probability of radiative recombination is greatly improved. Moreover, recombination at the metal/polymer interface can be avoided as the LaF₃ layer separates the recombination zone from the metal electrode.

4. Conclusion

Thin layer of LaF₃ as a novel cathode buffer layer between the Al cathode and photoactive polymer in an organic solar cell (OSC) in organic solar cell has been investigated in this article. Thinner LaF₃ could induce LUMO/HOMO levels to have a more feasible level alignment for electron transport, and block holes. Substantial increase in the short-circuit current density and open-circuit voltage of the conventional OSC was observed.
#### Table 1. Summary of the experimental results.

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<tr>
<th>Solar cell parameters</th>
<th>LaF₃ thickness of 3 nm</th>
<th>LaF₃ thickness of 5 nm</th>
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<tr>
<td></td>
<td>Without anneal</td>
<td>Anneal at 150°C for 20 minutes</td>
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<tr>
<td>( V_{oc} )</td>
<td>0.68 V</td>
<td>1.0 V</td>
</tr>
<tr>
<td>( J_{sc} )</td>
<td>4.3 ( \mu A/cm^2 )</td>
<td>27 ( \mu A/cm^2 )</td>
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Extremely smooth surface of amorphous LaF₃ as obtained by AFM image favored its diffusion barrier characteristics for ambient oxygen and Al ions that degraded the organic layer and thereby reduced solar cell stability and lifetime. Therefore along with performance enhancement LaF₃ is expected to enhance the stability and lifetime of organic solar cell. All together, very thin LaF₃ can be considered as a very promising material that can be used in organic solar cells as a cathode buffer layer.

#### References


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